16dec05 12:53:37 User259284 Session D3436.2

DIALOG File 2: INSPEC 1898-2005/Dec W1

(c) Institution of Electrical Engineers

```
Set
        Items
                Description
         2173
                CI='SIH4'
S1
          569
                CI='SI2H6'
S2
S3
           11
                SI2H6
S4
           31
               SIH4
S5
         7812
               SILAN?
S6
         904
               DISILAN?
S7
         1286
                SILYL?
          54
               DISILYL?
S8
S9
         200
               METHYLSILAN?
           27
               METHYLSILYL?
S10
               METHYLDISILYL?
S11
           4
S12
           0
               DIMETHYLDISILYL?
S13
          57
               DIMETHYLSILYL?
S14
          84
               DIMETHYLSILAN?
S15
           0
               METHYLDISILAN?
            5
               DIMETHYLDISILAN?
S16
               TRIMETHYLDISILAN?
S17
           1
S18
          10
               TETRAMETHYLDISILAN?
               PENTAMETHYLDISILAN?
S19
           4
S20
         126
               HEXAMETHYLDISILAN?
S21
               HEXAMETHYLSILAN?
S22
            0
               PENTAMETHYLSILAN?
         541
               TETRAMETHYLSILAN?
S23
        137
S24
               TRIMETHYLSILAN?
S25
          84
               DIMETHYLSILAN?
           38
               MONOMETHYLSILAN?
S26
               MONOMETHYLDISILAN?
S27
            0
        11931
               S1:S27
S28
                S28 AND CI=RU EL
S29
                S28 AND (RU OR RUTHENIUM) (1N) (COAT????? OR ELEMENTAL OR PU-
S30
            RE OR LAYER???? OR DEPOSIT???? OR COAT???? OR REDUC???? OR FI-
            LM??)
S31
            6
                S29:S30
           0
                S28 AND (RU OR RUTHENIUM) (2N) ADHE?????????
S32
                S28 AND (RU OR RUTHENIUM) (5N) ADHE?????????
S33
          0
                S28 AND (RU OR RUTHENIUM) (8N) ADHE??????????
S34
           0
           18 (RU OR RUTHENIUM) (8N) ADHE??????????
S35
           1
               S30 AND CI=SI
S36
                S30 AND CI=GE
S37
               S30 AND SEMICOND??????????
S38
S39
               S36:S38
```

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S6 AND (SIH4 OR SI2H6)

S9

O

```
SYSTEM:OS - DIALOG OneSearch
  File 23:CSA Technology Research Database 1963-2005/Dec
  File 2:INSPEC 1898-2005/Dec W1
       6:NTIS 1964-2005/Dec W1
  File
        8:Ei Compendex(R) 1970-2005/Dec W1
  File
  File 14: Mechanical and Transport Engineer Abstract 1966-2005/Dec
  File 25:Weldasearch-19662005/Nov (c) TWI Ltd
  File 31: World Surface Coatings Abs 1976-2005/Dec
  File 33:Aluminium Industry Abstracts 1966-2005/Dec
  File 34:SciSearch(R) Cited Ref Sci 1990-2005/Dec W2
  File 35:Dissertation Abs Online 1861-2005/Nov
  File 36:MetalBase 1965-20051215
  File 46:Corrosion Abstracts 1966-2005/Dec
  File 56:Computer and Information Systems Abstracts 1966-2005/Dec
  File 57:Electronics & Communications Abstracts 1966-2005/Dec
  File 60:ANTE: Abstracts in New Tech & ENGINEER 1966-2005/NOV
  File 61:Civil Engineering Abstracts. 1966-2005/Dec
  File 63:Transport Res(TRIS) 1970-2005/Nov
  File 64:Environmental Engineering Abstracts 1966-2005/Dec
  File 65:Inside Conferences 1993-2005/Dec W2
  File 68:Solid State & Superconductivity Abstracts 1966-2005/Dec
  File 81:MIRA - Motor Industry Research 2001-2005/Oct
  File 94:JICST-EPlus 1985-2005/Oct W2
  File 95:TEME-Technology & Management 1989-2005/Nov W1
  File 96:FLUIDEX 1972-2005/Dec
  File 99:Wilson Appl. Sci & Tech Abs 1983-2005/Oct
  File 103: Energy SciTec 1974-2005/Oct B2
  File 104:AeroBase 1999-2005/Nov
  File 118:ICONDA-Intl Construction 1976-2005/Oct
  File 134: Earthquake Engineering Abstracts 1966-2005/Dec
  File 144:Pascal 1973-2005/Dec W1
  File 239:Mathsci 1940-2005/Jan
  File 240: PAPERCHEM 1967-2005/Dec W2
  File 248:PIRA 1975-2005/Nov W4
  File 293: Engineered Materials Abstracts 1966-2005/Dec
  File 315: ChemEng & Biotec Abs 1970-2005/Dec
  File 323: RAPRA Rubber & Plastics 1972-2005/Nov
  File 335:Ceramic Abstracts/World Ceramics Abstracts 1966-2005/Dec
  File 434:SciSearch(R) Cited Ref Sci 1974-1989/Dec
Set
         Items
                 Description
S1
          274
                 (RU OR RUTHENIUM) (8N) ADHE??????????
S2
          2062
                 (RU OR RUTHENIUM) (8N) INTERFAC???????
S3
       456151
                 (OXIDE? ? OR SILICA OR SILICATE? ? OR SIO OR SIO2 OR DIOXIDE??)
(8N) (SURFACE?? OR ADHES????? OR ADHER????? OR INTERFAC?????)
                 (RU OR RUTHENIUM) (2N) (DEPOSIT???? OR COAT???? OR LAYER???? OR FILM??)
          9645
S5
        11094
                 S1 OR S2 OR S4
          998
                 S5 AND S3
S6
S7
             7
                 S6 AND (SILAN? OR SILYL?)
S8
             0
                 S6 AND (DISILAN? OR DISILYL?)
```

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SYSTEM:OS - DIALOG OneSearch

File 348: EUROPEAN PATENTS 1978-2005/Dec W02

(c) European Patent Office

File 349:PCT FULLTEXT 1979-2005/UB=20051208,UT=20051201

(c) WIPO/Univentio

Set	Items	Description
S1	43843	IC=H01L-021?
S2	378	S1 AND (RU OR RUTHENIUM)/TI,AB,CM
S3	1230	S1 AND (SILAN? OR DISILAN? OR SIH4 OR SI2H6)/TI,AB,CM
S4	1185	S1 AND (SILANE? OR DISILANE? OR SIH4 OR SI2H6)/TI,AB,CM
S5	19	S2 AND S3:S4
S6	258	S2 AND (SIO OR SIO2 OR SILICA????? OR OXIDE?? OR DIOXID???-
)/	TI,AB,CM
S7	14	5AND6
S8	13	S7 AND (INTERFAC???? OR SURFAC??? OR TREAT???? OR ADHES???-
	??	OR ADHER?????)/TI,AB,CM
S9	14	S7:S8

CAS/STN plurals and abbreviations are turned on.

```
CAS/STN FILE 'HCAPLUS' ENTERED AT 11:06:45 ON 16 DEC 2005
              1 S (US2003-418411/PRN OR US2003-418411/AP)
Ll
                SEL PLU=ON L1 1- IC NCL INCL :
L2
     FILE 'REGISTRY' ENTERED AT 11:07:40 ON 16 DEC 2005
             1 S SILANE/CN
L3
              1 S DISILANE/CN
L4
L5
            343 S
                   (SILANE OR DISILANE) AND (H SI/ELF OR H.SI/MF)
             10 S (SILANE OR DISILANE) AND (D SI/ELF OR
L6
         171575 S (SILANE OR DISILANE)
L7
            21 S L7 AND (D H SI/ELF OR D.H.SI/MF)
L8
L9
             1 S L7 AND (SI T/ELF OR SI.T/MF)
             3 S L7 AND (D SI T/ELF OR D.SI.T/MF)
L10
              4 S L7 AND (H SI T/ELF OR H.SI.T/MF)
L11
L12
             0 S L7 AND (D H SI T/ELF OR D.H.SI.T/MF)
L13
       630447 S (SILYL? OR SILANE? OR DISILANE? OR DISILYL?) AND (METHYL OR METHAN?)
L14
         145533 S L7 AND METHYL
L15
           787 S L7 AND METHANE
L16
           290 S DISILYL? AND (METHYL? OR METHANE?)
      3980 S DISILINE? AND (METHYL: OR METHANE?)

146201 S (L3 OR L4 OR L5 OR L6) OR (L8 OR L9 OR L10 OR L11) OR (L14 OR L15 OR L16 OR L17)

34129 S (SI OR GE)/ELS, MAC AND OXIDE
L17
L18
L19
          7165 S SILICA
L20
          25836 S SILICATE
L21
          3634 S GERMANATE
L22
          22414 S GE O/ELF OR GE.O/MF OR O SI/ELF OR O.SI/MF
L23
     FILE 'HCAPLUS' ENTERED AT 11:21:05 ON 16 DEC 2005
L24
           2014 S SEMICONDUCT###### OXIDE
L25
           8176 S SEMICONDUCT######/TI AND OXIDE/TI
L26
           670 S L24 AND L25
                SEL PLU=ON L26 1- RN :
L27
                                          849 TERMS
     FILE 'REGISTRY' ENTERED AT 11:22:09 ON 16 DEC 2005
          849 S L27
1.28
          412 S L28 AND OXIDE
58322 S (L19 OR L20 OR L21 OR L22 OR L23) OR L29
L29
L30
             1 S RUTHENIUM/CN
L31
           7303 S RU/ELS, MAC AND ALLOY?
L32
           890 S L32 AND RU>50/MAC
L33
    FILE 'HCAPLUS' ENTERED AT 11:24:48 ON 16 DEC 2005
        35633 S L33 OR L31 OR (PURE OR ELEMENTAL) (W) (RU OR RUTHENIUM)
          1404 S METAL##### (A) (RU OR RUTHENIUM)
L36
           927 S (RU OR RUTHENIUM) (W) (LAYER OR FILM OR OVERLAYER OR CAP OR FILM OR COAT#####)
          1155 S (RU OR RUTHENIUM) (2A) (DEPOSIT##### OR CVD OR ALD OR PECVD)
L37
          36694 S (L34 OR L35 OR L36 OR L37)
L38
          12984 S L38 AND (L24 OR L30)
L39
           185 S L39 AND (L18 OR SIH4 OR SI2H6 OR METHYLSILANE OR SILYLMETHANE OR METHYLDISILANE OR
L40
DISILYLMETHANE)
             20 S L39 AND (?DISILANE? OR ?SILANE? OR
                ?DISILYL? OR ?SILYL?) (2A) (?METHANE? OR METHYL?)
             11 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) DIMETHYL?
L42
              6 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) TRIMETHYL?
L43
             0 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL?) (2A)BIMETHYL?
L44
             2 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) TETRAMETHYL?
T.45
             1 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) PENTAMETHYL?
1.46
             1 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL?) (2A) HEXAMETHYL?
L47
             O S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?)(2A)PERMETHYL?
             0 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) MONOMETHYL?
L49
             0 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) MONOMETHANE?
L50
             0 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) PERMETHANE?
L51
L52
             O S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) DIMETHANE?
             0 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) TRIMETHANE?
L53
             0 s L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) TETRAMETHANE?
L54
```

```
FILE 'HCAPLUS' ENTERED AT 11:24:48 ON 16 DEC 2005
             0 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL?) (2A) PENTAMETHANE?
             0 S L39 AND (?DISILANE? OR ?SILANE? OR ?DISILYL? OR ?SILYL?) (2A) HEXAMETHANE?
L56
           189 S (L40 OR L41 OR L42 OR L43 OR L44 OR L45 OR L46 OR L47)
L57
             1 S L57 AND (OXIDE OR SIO OR SIO2 OR DIOXIDE OR GEO##) (3A) EXPOS############
L58
                  L57 AND (OXIDE OR SIO OR SIO2 OR DIOXIDE OR GEO##) (3A) TREAT##########
             3 S
L59
             0 S
                  L57 AND (OXIDE OR SIO OR SIO2 OR DIOXIDE OR GEO##) (3A) AFTER
L60
             0 S L57 AND (OXIDE OR SIO OR SIO2 OR DIOXIDE OR GEO##)(3A)FOLLOW##########
L61
             0 S L57 AND (OXIDE OR SIO OR SIO2 OR DIOXIDE OR GEO##)(3A)SUBSEQUENT#######
L62
             1 S L57 AND (OXIDE OR SIO OR SIO2 OR DIOXIDE OR GEO##) (3A) "STEP"
L63
           7812 S L2
L64
L65
             7 S L64 AND L57
             11 S (L58 OR L59 OR L60 OR L61 OR L62 OR L63) OR L65
L66
     FILE 'STNGUIDE' ENTERED AT 11:38:34 ON 16 DEC 2005
     FILE 'HCAPLUS' ENTERED AT 11:43:27 ON 16 DEC 2005
         87269 S SURFACE (3A) TREAT#####
         29747 S SURFACE (3A) GAS#######
L68
         11322 S SURFACE (3A) VAPOR########
L69
           28 S SURFACE (3A) VAPOUR########
L70
L71
          8388 S SURFACE (3A) ANNEAL########
         93864 S SURFACE (3A) (RTP OR RTA OR HEAT#### OR EXPOS#### OR THERMAL#####)
L72
          7382 S SURFACE (3A)?SILANE?
L73
             2 S L57 AND L73
L74
             5 S L57 AND (L67 OR L68 OR L69 OR L70 OR L71 OR L72)
L75
             6 S (L74 OR L75)
L76
             4 S L76 NOT L66
L77
     FILE 'STNGUIDE' ENTERED AT 11:45:49 ON 16 DEC 2005
     FILE 'HCAPLUS' ENTERED AT 11:48:49 ON 16 DEC 2005
        199175 S (FORM##### OR DEPOSIT#####) (2A) (OXIDE OR DIOXIDE OR SILICA OR SILICATE OR SIO OR
L78
SIO2)
        104074 S (SURFACE OR TREAT#####) (2A) (OXIDE OR DIOXIDE OR SILICA OR SILICATE OR SIO OR SIO2)
L79
         28946 S (OXIDIZ? OR REOXID? OR OXIDIS? OR OXIDAT?
L80
               OR OXIDED OR OXIDI?) (3A) (SI OR SILICON OR GE OR GERMANIUM OR SEMICOND######)
L81
             22 S L57 AND L78
             7 S L57 AND L79
L82
             0 S L57 AND L80
L83
                  (L81 OR L82) NOT (L77 OR L66)
L84
             21 S
             6 S L84 AND (RU OR RUTHENIUM)/TI, AB
L85
             0 S L84 AND (SILANE? OR DISILANE?)/TI,AB
L86
             0 S L84 AND SIH4/TI,AB
L87
              0 S L84 AND SI2H6/TI, AB
L88
     FILE 'STNGUIDE' ENTERED AT 11:53:27 ON 16 DEC 2005
     FILE 'HCAPLUS' ENTERED AT 11:56:52 ON 16 DEC 2005
          16864 S (RU OR RUTHENIUM) (7A) (OXIDE OR DIOXIDE OR SILICA OR SIO OR SIO2 OR SILICATE)
1.89
            619 S (RU OR RUTHENIUM) (7A) (?SILANE? OR ?DISILANE? OR ?SIH4? OR ?SI2H6?)
1.90
L91
          24962 S ((OXIDE OR DIOXIDE OR SILICA OR SIO OR
                SIO2 OR SILICATE) (7A) (?SILANE? OR ?DISILANE? OR ?SIH4? OR ?SI2H6?))
             40 S L57 AND L89
L92
             20 S L57 AND L90
L93
            32 S L57 AND L91
L94
            61 S (L92 OR L93 OR L94)
L95
            53 S L95 NOT (L85 OR L77 OR L66)
L96
             8 S L96 AND L92 AND L93
L97
            17 S L96 AND L92 AND L94
L98
             8 S L96 AND L93 AND L94
L99
             6 S L97 AND L98 AND L99
```

FILE 'STNGUIDE' ENTERED AT 11:59:52 ON 16 DEC 2005

L100

```
FILE 'HCAPLUS' ENTERED AT 12:01:20 ON 16 DEC 2005
L101
             47 S L96 NOT L100
              4 S L101 AND SEMICONDUCT##########/TI,AB
L102
     FILE 'STNGUIDE' ENTERED AT 12:01:48 ON 16 DEC 2005
     FILE 'HCAPLUS' ENTERED AT 12:03:45 ON 16 DEC 2005
L103
            687 S (RU OR RUTHENIUM) (W) (LAYER OR FILM)
                   (OXIDE OR DIOXIDE OR SIO OR SIO2 OR SILICA OR SILICATE) (W) (LAYER OR FILM)
L104
         136364 S
            158 S L57 NOT (L85 OR L77 OR L66 OR L100 OR L102)
L105
              0 S L103 AND L105
L106
              5 S L104 AND L105
L107
     FILE 'STNGUIDE' ENTERED AT 12:06:20 ON 16 DEC 2005
     FILE 'HCAPLUS' ENTERED AT 12:08:36 ON 16 DEC 2005
           2643 S (RU OR RUTHENIUM) (5A) (SILICA OR SILICATE
L108
                OR SIO OR SIO2 OR SEMICONDUCT########)
1.109
          17709 S (?SILANE? OR ?DISILANE?) (5A) (SILICA OR
                SILICATE OR SIO OR SIO2 OR SEMICONDUCT########)
            534 S (?SILANE? OR ?DISILANE?) (5A) (RU OR
L110
                RUTHENIUM)
             49 S L108 AND L109
L111
L112
             35 S
                  L108 AND L110
L113
             22 S
                  L109 AND L110
                   (L111 OR L112 OR L113) NOT (L85 OR L77 OR L66 OR L100 OR L102 OR L107)
L114
             72 S
             9 S L114 AND L57
L115
             10 S L114 AND SEMICONDUCT#########
L116
             16 S (L115 OR L116)
L117
     FILE 'STNGUIDE' ENTERED AT 12:10:40 ON 16 DEC 2005
     FILE 'HCAPLUS' ENTERED AT 12:16:02 ON 16 DEC 2005
L118
            101 S ADHE######## (3A) (RU OR RUTHENIUM)
              2 S L57 AND L118
L119
          68686 S OXIDE (4A) SURFACE
L120
          30842 S OXIDE (4A) TREAT#######
L121
          94343 S
                   TREAT####### (4A) SURFACE
L122
L123
           5934 S
                  L120 AND (L121 OR L122)
           3388 S
                  L121 AND L122
L124
L125
           2292 S L123 AND L124
              2 S L57 AND L125
L126
              1 S L126 NOT L119
L127
     FILE 'STNGUIDE' ENTERED AT 12:18:54 ON 16 DEC 2005
     FILE 'HCAPLUS' ENTERED AT 12:20:50 ON 16 DEC 2005
                  (OXIDE OR SILICA OR SILICATE OR SIO OR
L128
                SIO2) (W) (FILM OR LAYER OR SURFACE OR INTERFACE OR ADHE########)
L129
           1558 S (RU OR RUTHENIUM) (W) (FILM OR LAYER OR
                SURFACE OR INTERFACE OR ADHE#######)
            122 S L128 AND L129
T-130
L131
            119 S (L34 OR L35 OR L36 OR L37 OR L38 OR L39 OR L40 OR L41 OR L42 OR L43 OR L44 OR L45
OR L46 OR L47 OR L48 OR L49 OR L50 OR L51 OR L52 OR L53 OR L54 OR L55 OR L56 OR L57 OR L58 OR L59 OR
L60 OR L61 OR L62 OR L63 OR L64) AND L130
L132
              7 S (L71 OR L72 OR L73) AND L130
             77 S (L78 OR L79 OR L80) AND L130
L133
            122 S (L131 OR L132 OR L133)
L134
L135
             3 S L119 OR L127
L136
             19 S L117 OR L135
             16 S L136 NOT (L85 OR L77 OR L66 OR L100 OR L102 OR L107)
L137
              2 S L137 AND ?SIH4?
L138
L139
              2 S L137 AND ?SI2H6?
L140
             1 S L137 AND ?SILYL?
             16 S L137 AND ?SILAN?
L141
1.142
             16 S
                   (L138 OR L139 OR L140 OR L141)
              2 S
                  L142 AND ADHE#########
L143
              O S L142 AND (RU OR RUTHENIUM) (W) (METAL##### OR FILM OR LAYER### OR COAT##### OR
L144
```

DEPOSIT####)

FILE 'HCAPLUS' ENTERED AT 12:20:50 ON 16 DEC 2005 4 S L142 AND (RU OR RUTHENIUM)/AB 1.145 2 S L142 AND (RU OR RUTHENIUM)/ST L146 1 S L142 AND (RU OR RUTHENIUM)/TI L147 16 S L142 AND (RU OR RUTHENIUM)/IT L148 16 S (L145 OR L146 OR L147 OR L148) L149 FILE 'STNGUIDE' ENTERED AT 12:26:01 ON 16 DEC 2005 FILE 'HCAPLUS' ENTERED AT 12:29:54 ON 16 DEC 2005 1 S (RU OR RUTHENIUM) (W) COATED (W) (OXIDE OR SILICA OR SILICATE OR SIO OR SI DIOXIDE OR L150 SEMICONDUCT###### OR SILICON)

FILE 'STNGUIDE' ENTERED AT 12:30:02 ON 16 DEC 2005

FILE 'HCAPLUS' ENTERED AT 12:32:15 ON 16 DEC 2005 88 S L64 AND (L38 OR L118 OR L129) AND L128 L151 5 S L151 AND (L18 OR ?SILAN? OR ?SILYL?) L152

FILE 'STNGUIDE' ENTERED AT 12:34:16 ON 16 DEC 2005

FILE 'HCAPLUS' ENTERED AT 12:40:40 ON 16 DEC 2005 L153 5 S L152 AND (L31 OR L32)

FILE 'STNGUIDE' ENTERED AT 12:40:55 ON 16 DEC 2005

FILE 'DPCI' ENTERED AT 12:42:58 ON 16 DEC 2005 L154 2 **S** US 6737313/PN.D SEL PLU=ON L154 1- PRN : 2 TERMS L155

20 **S** US 6737313/PN.G L156

2 **S** L155 L157

SEL PLU=ON L157 1- PN.D : L158

235 S L158 L159

249 **S** L156 OR L157 OR L159 L160

L161 SEL PLU=ON L160 1- PRN :

FILE 'WPIX, JAPIO, HCAPLUS' ENTERED AT 12:44:29 ON 16 DEC 2005

685 **S** L161 L162

L163 44 S L162 AND (RU OR RUTHENIUM) (W) (METAL#### OR FILM OR LAYER)

5 S L163 AND (?SILAN? OR ?SILYL? OR ?SIH4? OR ?SI2H6?) L164

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CAS/STN FILE 'REGISTRY' ENTERED AT 14:19:00 ON 16 DEC 2005
          4824 S RU/ELS, MAC AND SI/ELS, MAC
L1
          2690 S L1 NOT (OXIDE OR O/ELS, MAC OR SILICATE OR SILICA)
L2
        171575 S SILANE OR DISILANE
L3
        145533 S L3 AND METHYL
L4
           343 S L3 AND H SI/ELF
L5
           1 S L3 AND H SI/MF
L6
        145869 S (L4 OR L5 OR L6)
L7
    FILE 'HCAPLUS' ENTERED AT 14:21:40 ON 16 DEC 2005
L8
           240 S
                  L2 AND L7
L9
           128 S
                  L2 AND (?SILANE?)
           258 S
L10
                  (L8 OR L9)
            11 S L10 AND (ADHES####### OR ADHER###### OR
L11
              INTERFAC####### OR SURFACE)
    FILE 'REGISTRY' ENTERED AT 14:27:14 ON 16 DEC 2005
         47218 S SILICA### OR SI/ELS, MAC AND OXIDE
L12
    FILE 'HCAPLUS' ENTERED AT 14:27:35 ON 16 DEC 2005
L13
           10 S L10 AND L12
            9 S
                  L13 NOT L11
L14
    FILE 'REGISTRY' ENTERED AT 14:32:38 ON 16 DEC 2005
L15
          628 S
                  L1 AND SILANE
L16
          2425 S
                  L1 AND SILYL
L17
         2605 S
                   (L15 OR L16)
        693074 S SILICA##### OR (SI/ELS, MAC AND (O/ELS, MAC OR OXIDE))
L18
          386 S L18 AND O.SI/MF
L19
                  L18 AND O.RU.SI/MF
L20
           2 S
                  L18 AND N.O.SI/MF
L21
          408 S
          429 S L18 AND N O SI/ELF
L22
          4 S L18 AND O RU SI/ELF
L23
L24
         7165 S L18 AND SILICA
L25
         25836 S L18 AND SILICATE
    FILE 'HCAPLUS' ENTERED AT 14:36:53 ON 16 DEC 2005
           250 S
L26
                   L10 AND L17
           3 S
                  L10 AND (L19 OR L20 OR L21 OR L22 OR L23 OR L24 OR L25)
L27
L28
           231 S
                  L26 NOT (L27 OR L14 OR L11)
L29
          175 S L28 NOT CATAL##########
L30
           34 S
                  L29 AND TREAT######
           89 S
                  L29 AND FORM#######
L31
           0 S
                  L29 AND (ADHES###### OR ADHER#####)
L32
           0 S L29 AND SURFACE
L33
           0 S L29 AND INTERFAC######
L34
           0 S L29 AND H01L?/IC
L35
           0 S L29 AND 438?/NCL
L36
           0 S
                  L29 AND 257?/NCL
L37
           0 S
                  L29 AND 716?/NCL
L38
           0 S
                  L29 AND 148?/NCL
L39
                  L29 AND SEMICONDUCT###########
           0 S
L40
           1 S
                  L29 AND ELECTRONICS
L41
           0 S
                  L29 AND MICROELEC?
L42
           0 S
                  L29 AND TRANSISTOR
L43
                  L29 AND THIN FILM
            0 S
L44
            0 S
L45
                   L29 AND TFT
    FILE 'STNGUIDE' ENTERED AT 14:41:38 ON 16 DEC 2005
    FILE 'HCAPLUS' ENTERED AT 14:42:45 ON 16 DEC 2005
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(RU OR RUTHENIUM OR OXIDE OR SILANE OR DISILANE)/TI AND (L30 OR L31)

71 S

1.46